Art Unit: 2818 SEP 1 3 2006

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13 September 2006

Date of Deposit

Graham S. Jones, 11: Reg. No. 20,429

Serial No.:

10/605,100

Name of Person Making Deposit

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

DV 09/26/06

Inventors:	Tina J. Wagner et al.	Date:	13 September 2006
Serial No.:	10/605,100 ,	Art Unit:	2818
Filing Date:	09 September 2003	Examiner:	David Vu
Confirmation No.:	2099	Docket No.:	F1S920030249US1
Title:	A Raised Source Drain MOSFET with Notch Formed on Top of Gate Structure Filled with a Dielectric Plug	Attorney:	Graham S. Jones, II 42 Barnard Avenue Poughkeepsie, NY 12603-5023

AMENDMENT AFTER FINAL REJECTION

BOX AF Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Your Honor:

In response to the Office Action of 21 July 2006, please amend the above-identified application as follows:

Amendments to the Claims

begin on page 2 of this paper.

Remarks/Arguments

begin on page 7 of this paper.

FIS920030249US1